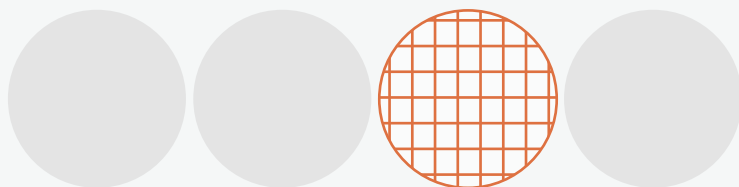


Taiwan-Europe Semiconductor Short-term Training Program 2024



Session I Jul 27- Aug 4

Semiconductor in Taiwan: Trends and Transformations
for 1 week: National Taiwan University

or The Essentials of Semiconductor Technology and Supply Chains
for 1 week: National Cheng Kung University

Session II Aug 5- Aug 16

Practical Training for 2 weeks:
Taiwan Semiconductor Research Institution



Semiconductor in Taiwan: Trends and Transformations

NTU Courses

| | Morning Session | Afternoon Session |
|---------------|--|---|
| JUL 27 | Arrival & Check-in | |
| JUL 28 | One Day Trip National Palace Museum/Tamsui | |
| JUL 29 | <ul style="list-style-type: none">- Campus Tour Orientation- Opening Ceremony Welcome Lunch | <ul style="list-style-type: none">- Introduction of Semiconductor in Taiwan- The History and Future of Chip Design and Manufacturing (Chip Wars) |
| JUL 30 | IC Technologies | Project Discussion |
| JUL 31 | Materials/Physics/ Chemistry -Sciences Behind Chips | Project Discussion |
| AUG 01 | The Future of Semiconductor Electronics | NTU Farm/ NTU Museum/ NTU NEMS Research Center |
| AUG 02 | Electronic Design Automation | <ul style="list-style-type: none">- Culture Excursion Shenkeng Old Street / Tofu DIY- Project Discussion |
| AUG 03 | Overview of Digital IC Design Flow | Project Discussion/ Rehearsal |
| AUG 04 | <ul style="list-style-type: none">- Hotel Check-out- Final Presentation Closing Ceremony- Farewell Lunch | Departure to TSRI |

** Schedule is subject to change

Taiwan-Europe Semiconductor Short-term Training Program

Semiconductor in Taiwan: Trends and Transformations

| Course | Description |
|--|---|
| <p>JUL 29</p> <p>14:00-15:00</p> <p>Introduction to Semiconductor Industry in Taiwan</p> <p>劉致為 Chee Wee Liu</p> | <p>Semiconductor industry are classified as IC + OSD (Optoelectronics/Sensors/Discrete) with the estimated market size of 600B USD WW in 2024. Display and solar cell do not belong to semiconductor industry. The largest foundry tsmc has the revenue around 70B USD, about 10% of WW revenue.</p> <p>IC has 4 categories, Logic/Micro/Memory/ Analog. Most advanced technologies are led by logic. The logic roadmap will be taught. Taiwan is strong in logic process, but weak in memory, micro, and analog.</p> <p>Although chip design in Taiwan is not as strong as foundry, CBI (Chip-based Industrial Innovation Program) is planned to invest 300B NT in the next decade (2024-2033) to strengthen the national IC design capabilities. However, no plans for memory are particularly proposed.</p> <p>GaN/SiC are also the focus of Taiwan's national programs. The recent revenues of each segment in TW will be presented.</p> |
| <p>JUL 29</p> <p>15:30-17:30</p> <p>The History and Future of Chip Design and Manufacturing (Chip Wars)</p> <p>陶儀芬 Yi-feng Tao</p> | <p>In this course, we will put the development of Taiwan's semiconductor industry in the context of global political economy. Based upon Chris Miller's Chip War, we will first briefly go through the history of semiconductor industry in the United States and Japan and then focus on how semiconductor manufacturing has developed in Taiwan and how China has tried to catch up and pose a challenge to the U.S.-led global supply chain of the chips. And then, we will address how the geopolitical competition between China and the U.S. since Xi Jinping came to power has reinforced the two superpowers' determination to decouple with each other in this industry. It has in terms complicated the status of Taiwan's Silicon Shield.</p> |
| <p>JUL 30</p> <p>09:30-12:00 13:30-16:00</p> <p>IC Technologies</p> <p>劉致為 Chee Wee Liu</p> | <p>What are the 7 nm, 5 nm, 3 nm even 2 nm nodes in the daily news? What is the definition of node names with the correlations of gate length/contact poly pitch/cell height? What do we need the FinFETs after planar transistors? Why do FinFETs have the difficulty to meet requirements of the technology nodes beyond 3 nm? Nanosheets after FinFETs can save the transistor scaling to continue Moore's law. How long can nanosheets last? What are after nanosheets? What the final destination of technology roadmap? Any end? I will show how to make planar/FinFET/nanosheets transistors by yourself, and the possible roadmap in the future. Nanoscale transistors have quantum behaviors beside the classical diffusion and drift, making colorful pictures of advanced transistors. Based on the amazing diamond structures of Si lattice, band diagram (physical points of view) and chemical bonding structure are the starting points to understand the electron and hole concentration, n-type vs p-type doping, and MOSFET device physics. Advanced transistors featuring small gate length, 3D structure, and sophisticated device physics which can be understood by TCAD simulation. The concepts with graphic drawing can help you to understand the transistor working principle. However, very simple math will be introduced to understand the scaling length and on-state currents</p> |

Taiwan-Europe Semiconductor Short-term Training Program

Semiconductor in Taiwan: Trends and Transformations

| Course | Description |
|--|---|
| <p>JUL 31</p> <p>09:30-12:00 13:30-16:00</p> <p>Materials/ Physics/ Chemistry- Sciences Behind Chips</p> <p>劉致為 Chee Wee Liu</p> | <p>Nanoscale transistors have quantum behaviors beside the classical diffusion and drift, making colorful pictures of advanced transistors. Based on the amazing diamond structures of Si lattice, band diagram (physical points of view) and chemical bonding structure are the starting points to understand the electron and hole concentration, n-type vs p-type doping, and MOSFET device physics. Advanced transistors featuring small gate length, 3D structure, and sophisticated device physics which can be understood by TCAD simulation. The concepts with graphic drawing can help you to understand the transistor working principle. However, very simple math will be introduced to understand the scaling length and on-state currents.</p> |
| <p>AUG 01</p> <p>09:30-12:00</p> <p>The Future of Semiconductor Electronics</p> <p>謝馬利歐 Mario Hofmann</p> | <p>Current electronic progress relies on the continued decrease in transistor dimensions to enhance circuit performance and decrease cost. However, fundamental physical problems arise when transistors are scaled toward nanometer size, including quantum mechanical tunneling, hot electrons, and loss of electrostatic control. This course will illustrate the origin of these issues and review the promise of nanomaterials to overcome them. Surprisingly, quantum mechanical processes are not only the source of scaling problems but may lead to new solutions. The lecture will introduce new developments in transistor operation and electronic circuits beyond FETs and describe new ideas for computation that do not rely on traditional circuits and binary logic.</p> |
| <p>AUG 02</p> <p>09:30-12:00</p> <p>Electronic Design Automation</p> <p>江蕙如 Iris Hui-Ru Jiang</p> | <p>The increasing design complexity and continuous technology scaling pose a tough challenge to chip design or even system design. Nowadays, Electronic Design Automation (EDA) tools become vital to tackle this challenge. In this course, we will mainly focus on VLSI design automation. This course covers front-end and back-end design automation techniques.</p> |
| <p>AUG 03</p> <p>09:30-12:00</p> <p>Overview of Digital IC Design Flow</p> <p>吳安宇 An-Yeu (Andy) Wu</p> | <p>Computing tools have evolved from the abacus to modern billion-transistor CPUs and GPUs. One of the primary reasons for this advancement is the invention of integrated circuits (ICs). In this lecture, we will provide a brief overview of the history of transistors, as well as their close relationship with computers and CPUs. We will use a simple MIPS CPU design (detailed design is not covered) to illustrate the digital IC design flow by using front-end and back-end EDA tools.</p> |

Taiwan-Europe Semiconductor Short-term Training Program

Semiconductor in Taiwan: Trends and Transformations

Instructor

Education and Major Research Areas

劉致為

Chee Wee Liu



Distinguished Professor,
Department of Electrical Engineering,
IEEE FELLOW

Ph.D., Electrical Engineering, Princeton University, 1994

His research includes SiGe/GeSn epi/photronics, stacked 3D transistors, RF device and circuit/thermal simulation (physics-based and machine learning-based), IGZO TFT, SRAM/MIM/FTJ, FRAM, FeFET/MTJ/SOT/DRAM, and Si photonics. He demonstrates the tallest transistor (8/16/24 stacked channels), the record high 2,400,000 cm²/Vs electron mobility in strained Si, the first Si-capped SiGe/Ge channels with 3x mobility enhancement (in 5nm node production now), the first CVD GeSn outperforming MBE in terms of hole mobility, the first stacked GeSn/GeSi channel GAA(nanosheet/nanowire) transistors, and the first Si/SiGe/SiC MIS LED/photodetectors. He also invented the tree/E transistors, beyond Stacked GAA. He has 718+ papers (277+ journal papers, 32 IEDM, 19VLSI), 86 US patents, 2 China patents, 57 Taiwan ROC patents, more than 8981+ citations with h-index=43, 44 Ph.D. graduates, and 143 master graduates. He has 5 graduate students as professors (2 NTU, 1 NCHU, 1 NDHU, 1 NJUST), and 3 postdocs as professors (1 NTU, 1 NCU, 1 CGU). Currently, he is advising 26 PhD students and 37 masters.

陶儀芬

Yi-feng Tao



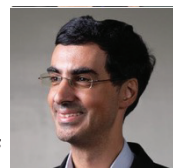
Associate Professor,
Department of Political
Science

Ph.D. Columbia University in New York City, 2001

1. Chinese politics
2. International Political Economy
3. Comparative Politics

謝馬利歐

Mario Hofmann



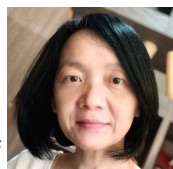
Professor, Department of
Physics

**Ph.D., Electrical Engineering,
Massachusetts Institute of Technology, 2011**

Nanoelectronics and nanomaterials

江蕙如

Iris Hui-Ru Jiang



Professor, Department of
Electrical Engineering

**Ph.D., Electronics Engineering,
National Chiao Tung University, 2002**

1. Timing analysis and optimization
2. Physical design
3. Design for manufacturability

吳安宇

An-Yeu Andy Wu



Distinguished Professor,
Department of Electrical
Engineering, IEEE FELLOW

Ph.D., Electric Engineering, University of Maryland, 1995

1. VLSI/CAD
2. Communication integrated circuits
3. Signal processing

NCKU

The Essentials of Semiconductor Technology and Supply Chains

- Overall of Courses in NCKU

| | Morning Session | Afternoon Session |
|------------------|--|---|
| JUL 27 | Arrival Check-in Welcome Reception | |
| JUL 28 | Cultural Tour -KAOHSIUNG- | |
| JUL 29 | - Opening Ceremony - IC Design Overview : _ Binary Logic & Arithmetic Modules _ Essences of Computer Organization _ Transform Design using HDL & EDA Tools | IC Design Overview : Smart sensing heterogeneous integration chip technology |
| JUL 30 | TSRI Advanced Packaging Technology/ Clean Room-Module Tour | Techniques of Nanomaterials and Nanocomposites (session 1) |
| JUL 31 | Industry/ Company Visit | |
| AUG 01 | - Semiconductor-based Nanophotonics and their applications - Semiconductor Fabrication | - Techniques of Nanomaterials and Nanocomposites (session 2) |
| AUG 02 | Latest Trend on Semiconductor Technology by Applied Materials Taiwan (session 1) | Latest Trend on Semiconductor Technology by Applied Materials Taiwan (session 2) |
| AUG 03 | Circular Economy of Electronics Industry (session 1) | - Circular Economy of Electronics Industry (session 2) - Final Presentation Farewell Dinner |
| AUG 04 | Departure for TSRI | |

** Schedule is subject to change

Taiwan-Europe Semiconductor Short-term Training Program

The Essentials of Semiconductor Technology and Supply Chains

Prof. Jen-Sue Chen

The most comprehensive selection of topics offered by the Academy of Innovative Semiconductor and Sustainable Manufacturing of NCKU. With a theme on the essentials of semiconductor technology and supply chains, a series of lectures will be delivered by both the Academy's faculty and industry experts from top-notch research centers and businesses in Taiwan for an inclusive presentation of this subject. The topics will include IC design, techniques of nanomaterials and nanocomposites, fundamentals of device physics and fabrication, advanced packaging technology with AI, IoT, and 5G application, digital twin and IC packaging, VLSI process integration, and device measurement. This course consists of 7 topics shown in the table.

| Course | | Description |
|-----------|---|--|
| JUL 29 | IC Design Overview | <p>Prof. Chih-Hung Kuo - Binary Logic & Arithmetic Modules Prof. Ing-Chao Lin - Essences of Computer Organization Prof. Lih-Yih Chiou - Transform Design using HDL & EDA Tools Director Hann-Huei Tsai - Smart sensing heterogeneous integration chip technology</p> <p>IC design overview is to introduce the fundamentals of IC design to those interested in this field. It starts from basic binary logic blocks followed by arithmetic modules. Modules are organized in a logical way to perform computation. Then how to transform and realize a design into an integrated circuit by hardware description language and state-of-the-art design tools. In the end, how one can validate and confirm the success of the design. A concise yet insightful view can help learners quickly grasp the essences of IC design. It would be highly useful to people who want to have a jump start and know how we train students in Taiwan.</p> |
| AUG 01 | Semiconductor-based nanophotonics and their applications | <p>The short course provides an introduction to nanophotonics based on semiconductors and their device applications. Types of optical resonators, including photonic crystals, antennas, and bound states in the continuum will be introduced. Applications of nanophotonic resonators to nanospectroscopy and cavity quantum electrodynamics (CQED) will also be discussed.</p> |
| AUG 01 | Semiconductor Fabrication | <p>Semiconductor Fabrication delves into the heart of the microelectronics industry, focusing on the manufacturing process of semiconductor devices. This course offers students an essential understanding of the steps involved in the fabrication of semiconductors, including material preparation, chemical/physical vapor deposition, photolithography, etching, and ion implantation. Students will gain insight into the sophisticated processes and innovations that enable the production of ever-smaller and more powerful semiconductor devices.</p> |

Prof.
Jui-Nung Liu

Prof.
Ying-Yuan Huang

Taiwan-Europe Semiconductor Short-term Training Program

The Essentials of Semiconductor Technology and Supply Chains

| Course | Description |
|---|---|
| JUL 30 TSRI-Heterogeneous Integration and Manufacturing Lab Tour | Dr. Pei Ling Li; Mr. Tang Yuan Fu; Mr. Laifu Tsai; Mr. Yuming Yeh; Mr. Shih Han Hsu Advanced Packaging Technology/Clean Room-Module Tour |
| JUL 30 Techniques of Nanomaterials and Nanocomposites Prof. Su-Wen Hsu | This course will introduce the basic principle of the fabrication of nanomaterials and nanocomposites. The unique properties of nanomaterials strongly depend on their morphology and composition, leading to specialized applications, such as sensing, optical and electronic devices. Therefore, the fabrication process of nanomaterials plays an important role in manipulating material properties. The properties of nanocomposites can be influenced by the intrinsic properties of individual materials and extrinsic properties of syngenetic effects between materials, which make it possible to engineer the desired properties of nanocomposites. This course also focuses on designing the special functions of nanomaterials and nanocomposites for desirable applications. |
| AUG 02 Latest Trend on Semiconductor Technology by Applied Materials Taiwan Dr. Samuel Chiu Dr. Albert Lan | Innovative 3DHI (3D Heterogeneous Integration) Packaging Technology Development □3D Heterogeneous Integration (3DHI) has been widely used as one of the effective enablers for “More-than-Moore” technology since the advanced wafer node scaling down relying on front-end technology is getting hard to achieve the goal of business return. □With traditional transistor pitch scaling facing fundamental challenges, 3D Heterogeneous Integration Packaging technologies adopting Through Si Via (TSV) and Hybrid Bonding are poised to help enabling the future AI / HPC device applications. □In this class, to help the students to realize the advantages of 3D Heterogeneous Integration (3DHI), market trend, technology benchmark, process challenges and its effective solutions for the following topics will be specifically addressed.□Topic Coverage:□1.3DHI Market Trend and Product Applications, focusing on AI / HPC□2.3DHI Technology for CPO (Co Package Optics)□3.3DHI Technology for COWOS(TSV/BVR) / Hybrid Bonding (C2W / W2W)□4.3DHI Technology for Advanced Substrate |
| AUG 03 Circular Economy of Electronics Industry Prof. Wei-Sheng Chen | The concept of circular economy has gained significant attention in recent years, with various industries adopting different systems to tackle issues. In Taiwan, the electronics industry is a key contributor to the economy, but it also generates a significant amount of waste, pollution, and some problems. Therefore, there is a pressing need to improve the sustainability of this sector. This class aims to introduce some systems and recycling technologies (silicon resources) which can help Taiwan achieve the goals of the circular economy and address these challenges. |

Taiwan-Europe Semiconductor Short-term Training Program

The Essentials of Semiconductor Technology and Supply Chains

Instructor

About

陳貞夙

Prof. Jen-Sue Chen



Ph.D., California Institute of Technology,
USA

Professor

**Dept. Material Science and Engineering &
Program on Key Material, NCKU**

Thin Film Transistors, Light Gating Transistors, Resistance Switching RAMs, Charge Trapping Memory, Impedance Spectroscopy on Electronic Devices

郭致宏

Prof. Chih-Hung Kuo



PhD, Electrical Engineering, University of Southern California

Professor

**Dept. Electrical Engineering & Program
on Integrated Circuit Design, NCKU**

IC Design/ Electrical Engineering

林英超

Prof. Ing-Chao Lin



PhD, Computer Science and Engineering, Pennsylvania State University

Professor

**Dept. Computer Science and Information Engineering &
Program on Integrated Circuit Design, NCKU**

IC Design/ Computer Science & Information Engineering

邱瀝毅

Prof. Lih-Yih Chiou



PhD, VLSI and Circuit Design, Purdue University

IC Design/ Electrical Engineering

IC Design/ Electrical Engineering

蔡瀚輝

Director Hann-Huei Tsai



Master of Science Electrical Engineering,
National Cheng Kung University

**Research Fellow/Division Director,
National Applied Research Laboratories (NARLabs),
Taiwan Semiconductor Research Institute(TSRI), Tainan**

IC Design

劉瑞農

Prof. Jui-Nung Liu



PhD, Electrical and Computer Engineering, University of Illinois at Urbana-Champaign

Assistant Professor

Dept. Electrical Engineering and Institute of Microelectronics & Program on Semiconductor Manufacturing Technology, NCKU

Mid-infrared group-IV photonics/Optical nanocavity/ Surface-enhanced vibrational spectroscopy/Cavity QED

Taiwan-Europe Semiconductor Short-term Training Program

The Essentials of Semiconductor Technology and Supply Chains

Instructor

About

黃英原

Prof. Ying-Yuan Huang



Ph.D., Electrical and Computer Engineering, Georgia Institute of Technology, Atlanta, GA, USA

Professor

Dept. Material Science and Engineering & Program on Key Material, NCKU

High-efficiency silicon solar cells; Tunnel Oxide Passivated Contacts; Light Emitting Diodes; Semiconductor device simulation, fabrication and characterization

許蘇文

Prof. Su-Wen Hsu



PhD, Materials Science and Engineering, University of California, San Diego

Associate Professor

Dept. Chemical Engineering & Program on Key Materials, NCKU

Key Materials/Chemical Engineering

邱興邦

Dr. Samuel Chiu



PhD, Materials Science and Engineering, University of California, Los Angeles (UCLA)

Senior Technical Director, Applied Materials Taiwan

Semiconductor fabrication flow and integration/ Plasma and thermal applications in semiconductor process technology/ Materials and Failure Analysis tools and applications/ Quality Assurance and Supplier Chain Engineering/ Large Scale product and project management.

藍章益

Dr. Albert Lan



Global Sr. Packaging Account TD Head, Applied Materials, USA

Over 30 years of job experience in semiconductor industry, esp. advanced packaging technologies.
Senior Engineering Center Director, 14 years, SPIL
PD, Quality, & Sales, 6 years, Amkor Taiwan
Advanced 3D Heterogeneous Integration Packaging Technology Development

陳偉聖

Prof. Wei-Sheng Chen



PhD, Resource Engineering, NCKU

Associate Professor

Dept. Resource Engineering, NCKU

Waste Disposal
Resource Technology
Mineral
Waste Classification
Refined Metallurgy

Overall of Courses in TSRI

8/05-8/09

- | | |
|-------------------|---|
| R303 | - Full-Custom IC Design and Simulation |
| R305 | - Full-Custom IC Design and Simulation |
| Tainan New | - Operational Amplifier Design Essentials |

8/12-8/16

- | | |
|-------------------|---|
| R423 | - Silicon Photonics Design and Analysis |
| R303 | - CMOS RF IC Design and Simulation |
| Tainan New | - Power Management IC Design in CMOS BCD Technologies |

01 Full-Custom IC Design & CMOS RF IC Design

Full-Custom IC Design and Simulation (1-week)

Day 1

- Full-Custom IC Design Overview
- Foundry Design Kit Introduction

Day 2

- Fundamentals of Full-Custom Cell Design and Simulation

Day 3

- Layout Skill and Implementation

Day 4

- Layout Verification (DRC/LVS/LPE) and Debugging

Day 5

- Hands on Labs for Layout and Post-Sim.

CMOS RF IC Design and Simulation (1-week)

Day 6

- Passive Components
- Matching Networks

Day 7

- EM Simulation
- MOS Devices

Day 8

- Verification Flow

Day 9

- LNA Project Design

Day 10

- LNA Layout and Verification

02 Full-Custom IC Design & Silicon Photonics Design and Analysis

Full-Custom IC Design and Simulation (1-week)

Day 1

- Full-Custom IC Design Overview
- Foundry Design Kit Introduction

Day 2

- Fundamentals of Full-Custom Cell Design and Simulation

Day 3

- Layout Skill and Implementation

Day 4

- Layout Verification (DRC/LVS/LPE) and Debugging

Day 5

- Hands on Labs for Layout and Post-Sim.

Silicon Photonics Design and Analysis (1-week)

Day 6

- Silicon photonics introduction
- Silicon photonics foundry-type process/platform
- Si waveguide

Day 7

- Grating coupler and spot size converter design
- Coupler testing

Day 8

- Silicon photonics related company visiting

Day 9

- Modulator types and modulation mechanism
- Photonic integrated circuit design and simulation

Day 10

- Photonic integrated circuit layout

03 Operational Amplifier Design Essentials & Power Management IC Design in CMOS BCD Technologies

Operational Amplifier Design Essentials (1-week)

Day 1

- Device & model introduction
- Specifications of OPamp
- Opamp architecture introduction

Day 2

- Gm/Id design concepts
- Single-stage OPamp design

Day 3

- Two-stage OPamp Design
- Common-mode Feedback
- Bias Circuit Design

Day 4

- Noise & PVT variation
- Lab-Single-stage OPamp design

Day 5

- Lab-Opamp simulation techniques by Virtuoso
- Lab-Opamp simulation techniques by Hspice

Power Management IC Design in CMOS BCD Technologies (1-week)

Day 6

- Introduction
- Process Overview
- High Voltage Circuit Design
- Design Environment I: Circuit Simulation

Day 7

- Chip Implementation I: Schematic and Circuit Simulation
- Design Environment II: Layout & Layout Verification

Day 8

- Protection Mechanism I: Internal LV Device
- Chip Implementation II: Level Shifter Layout and Verification

Day 9

- Protection Mechanisms II: (1) Internal HV Device (2) HV I/O Device & Parasitic ESD Rules
- Chip Implementation III: Level Shifter Layout and Verification

Day 10

- Chip Implementation IV: Full Chip Layout
- Chip Implementation V: Post-layout Simulation